

Title (en)

REDUCTION OF THE EFFECTS OF CAP-LIKE PROJECTIONS, DUE TO LASER ABLATION OF A METAL LEVEL BY USING A NON-CROSSLINKED LIGHT- OR HEAT-CROSSLINKABLE POLYMER LAYER

Title (de)

MINIMIERUNG DER EFFEKTE VON SCHIRMARTIGEN PROJEKTIONEN DURCH LASERABLATION EINES METALLNIVEAUS ANHAND DER VERWENDUNG EINER NICHTVERNETZTEN LICHT- ODER WÄRMEVERNETZBAREN POLYMERSCHICHT

Title (fr)

Diminution des effets de casquettes dues à l'ablation laser d'un niveau métallique par utilisation d'une couche de polymère photo- ou thermo-réticulable non réticulé

Publication

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Application

EP 11731442 A 20110421

Priority

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Abstract (en)

[origin: WO2011138539A1] The invention relates to the use of a laser-crosslinkable material (10) that is non-crosslinked or partially crosslinked for protecting the electrodes of an organic transistor during laser etching.

IPC 8 full level

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CPC (source: EP KR US)

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Citation (search report)

See references of WO 2011138539A1

Citation (examination)

- US 2009127544 A1 20090521 - SCHRODNER MARIO [DE], et al
- US 2005236985 A1 20051027 - HANDA SHINICHI [JP], et al

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